

Preliminary Announcement

7th International Conference on Optics-photonics Design & Fabrication

“ODF '10, Yokohama”

April 19-21, 2010

Pacifico Yokohama (パシフィコ横浜), Japan

Co-located with LENS EXPO 2010

Organized by the Optics Design Group (ODG) of the Optical Society of Japan (OSJ)

Sponsored by the OSJ (An Affiliate of the Japan Society of Applied Physics)

Scope: ODF'10 is an international forum for the engineers and scientists in field of Optics-photonics Design and Fabrication to exchange their ideas and achievements for the future mutual progress. The conference will consist of the session for optics-photonics design, simulation, optical components, optical systems, and optical technology. These sessions will cover the field of optical theory, fabrication and testing, software, DOE's, micro-optics, nano-optics, photonic crystals, near-field optics, thin films, waveguides, MEMS, Lasers, fiber communications, information optics, optical storage, optical lithography, microscopy, displays, bio-science and others. A special session is also planned.

Paper Submission Due Date: October 20, 2009

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(Some of above committee members are under negotiation.)

ODF'10 Secretariat : Tsuyoshi HAYASHI / odf10@odf.jp

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